

ISO 22197-1:2016-11 (E)

Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for air-purification performance of semiconducting photocatalytic materials - Part 1: Removal of nitric oxide

Contents		Page
Foreword		iv
1	Scope	1
2	Normative references	1
3	Terms and definitions	2
4	Symbols	2
5	Principle	3
6	Apparatus	3
6.1	Test equipment	3
6.2	Test gas supply	3
6.3	Photoreactor	6
6.4	Light source	6
6.5	Analyser of pollutants	6
7	Test piece	6
8	Procedure	6
8.1	Pretreatment of test piece	6
8.2	Pollutant-removal test	7
8.3	Elution test	8
9	Calculation	8
9.1	Calculation method	8
9.2	Amount of NO _x adsorption by the test piece	9
9.3	Amount of NO removed by the test piece	9
9.4	Amount of NO ₂ formed by the test piece	9
9.5	Amount of NO _x desorbed from the test piece	10
9.6	Net amount of NO _x removed by the test piece	10
9.7	Nitrogen eluted from the test piece	10
9.8	Recovery of washing with water	11
10	Test method for test pieces with lower performance	11
11	Test report	11
Annex A (informative)	Results of round-robin test	12
Bibliography		13